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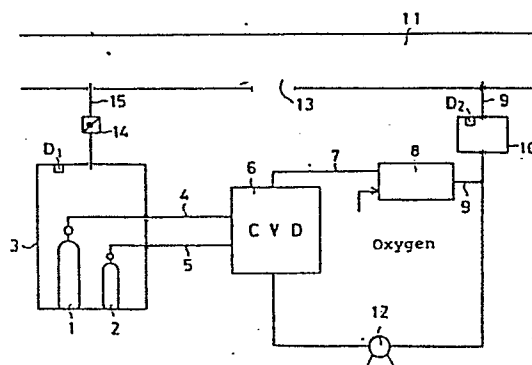
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⑤4 Alarm and control system for semiconductor manufacturing plants.

(57) This invention relates to an alarm and control system which detects leak of processing gas or a fire occurring in manufacturing process in very large-scale integrated circuit manufacturing plants, and adequate controls fire protection system such as fire extinguishing system and the manufacturing process.

Fig. 1





European Patent
Office

EUROPEAN SEARCH REPORT

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Application number

EP 83 11 1571

DOCUMENTS CONSIDERED TO BE RELEVANT

Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl. 3)
A	US-A-4 069 018 (KARNA et al.) * Column 2, line 50 - column 4, line 27 *	1,3,4	G 08 B 17/10
A	FR-A-2 226 813 (CIFAL) * Claims *	1	
A	US-A-4 267 889 (WILLIAMS) * Abstract *	1	
			TECHNICAL FIELDS SEARCHED (Int. Cl. 3)
			G 08 B A 62 C
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 09-06-1987	Examiner REEKMANS M.V.

CATEGORY OF CITED DOCUMENTS

X : particularly relevant if taken alone
Y : particularly relevant if combined with another document of the same category
A : technological background
O : non-written disclosure
P : intermediate document

T : theory or principle underlying the invention
E : earlier patent document, but published on, or after the filing date
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